

Special Issue

Process Control and Smart Manufacturing for Industry 4.0

Message from the Guest Editor

This Special Issue “Process Control and Smart Manufacturing for Industry 4.0” is focused on extended papers on the following topics:

- Process Automation
- Process Control and Monitoring
- Design Principles in Industry 4.0
- Smart Manufacturing and Technologies
- Smart Factories
- Machine Learning and Artificial Intelligence in Manufacturing
- Chemical Process Control

Submissions on other topics are also welcome provided they fit within the theme of the Special Issue.

Guest Editor

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Deadline for manuscript submissions

closed (1 December 2021)



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About the Journal

Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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